Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	944558	(flat near2 panel near3 (display device)) (field near2 emission near3 (display device source)) FPD FED	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:53
L3	232	2 and ((field near2 emission near3 source) same (planar carbon$6 nanotube low near2 work near2 function))	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:54
L4	23687	2 and cathode and gate	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:40
L6	111	3 and 4	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:21
L9	342	2 and cathode near2 electrode and ((gate control) near2 electrode) and ((focus focusing) near2 (electrode plate))	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:54
L10	250	9 and display	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:42
L11	17	10 and ((field near2 emission near3 source) same (planar carbon$6 nanotube low near2 work near2 function))	US-PGPUB; USPAT; USOCR	OR	ON	2004/12/10 11:43
L14	567567	(flat near2 panel near3 (display device)) (field near2 emission near3 (display device source)) FPD FED	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/10 11:53
L15	39	14 and cathode near2 electrode and ((gate control) near2 electrode) and ((focus focusing) near2 (electrode plate))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/10 12:24
L17	132	14 and ((field near2 emission near3 source) and (planar carbon$6 nanotube low near2 work near2 function))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/10 12:23
L18	54177	14 and (grid plate mesh)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/10 11:56
L22	7	18 and cathode near2 electrode and ((gate control) near2 electrode) and ((focus focusing) near2 (electrode plate))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/10 12:24